

EE 362 Electronic, Magnetic, & Opt. Prop. of Mat'ls Quiz 6 (Spring 2025)Name KEY A

Instructions: Open book/notes. Place answers in indicated spaces and **show all** work for credit. Carry *at least 6* significant figures on constants/parameters in calculations. Give answers with **3-4** significant figures.

A sample of gallium arsenide (GaAs) has an intrinsic carrier concentration of $1.79 \times 10^6 \text{ \#/cm}^3$, $E_g = 1.424 \text{ eV}$, and minority excess carrier lifetime of 25 \mu s at **300 K**. This sample is doped only with donors to a concentration of $2.2 \times 10^{17} \text{ \#/cm}^3$. Determine the thermal equilibrium electron and hole concentrations (\#/cm^3). Will the minority excess carriers be electron or holes? Then, find the ambipolar mobility ($\text{cm}^2/\text{V}\cdot\text{s}$) and diffusion (cm^2/s) coefficients under low-level injection conditions.

$$\text{Since } N_d \gg n_i \Rightarrow \underline{n_0 \cong N_d = 2.2 \times 10^{17} \text{ \#/cm}^3}.$$

$$(4.43) \ n_i^2 = n_0 p_0 \Rightarrow p_0 = n_i^2 / n_0 = (1.79 \times 10^6)^2 / 2.2 \times 10^{17} \Rightarrow \underline{p_0 = 1.4564 \times 10^{-5} \text{ \#/cm}^3}.$$

‘doped only with donors’ implies an n-type semiconductor (electrons in majority)
 \Rightarrow holes will be minority excess carriers

(6.47) & (6.48) give the ambipolar diffusion $D' = D_p$ and mobility $\mu' = -\mu_p$ coefficients for an n-type semiconductor w/ low-level injection.

Using Figure 5.3 (bottom graph for GaAs), draw a vertical line up from $N_i = N_d = 2.2 \times 10^{17} \text{ \#/cm}^3$ and read hole mobility to be $\mu_p = 200 \text{ cm}^2/\text{V}\cdot\text{s}$

$$\Rightarrow \underline{\mu' = -200 \text{ cm}^2/\text{V}\cdot\text{s}}.$$

Use Einstein Relation (5.47), $\frac{D_p}{\mu_p} = \frac{k_B T}{e}$ to get the hole diffusion coefficient-

$$D_p = \frac{k_B T}{e} \mu_p = \frac{1.380649 \times 10^{-23} (300)}{1.602176634 \times 10^{-19}} 200 \Rightarrow \underline{D_p = D' = 5.1704 \text{ cm}^2/\text{s}}.$$

minority excess carriers: electrons or holes (circle correct)

$$n_0 = \underline{2.2 \times 10^{17} \text{ \#/cm}^3} \quad p_0 = \underline{1.4564 \times 10^{-5} \text{ \#/cm}^3}$$

$$\text{ambipolar mobility} = \underline{\mu' = -200 \text{ cm}^2/\text{V}\cdot\text{s}} \quad \text{ambipolar diff. coeff.} = \underline{D' = 5.1704 \text{ cm}^2/\text{s}}$$

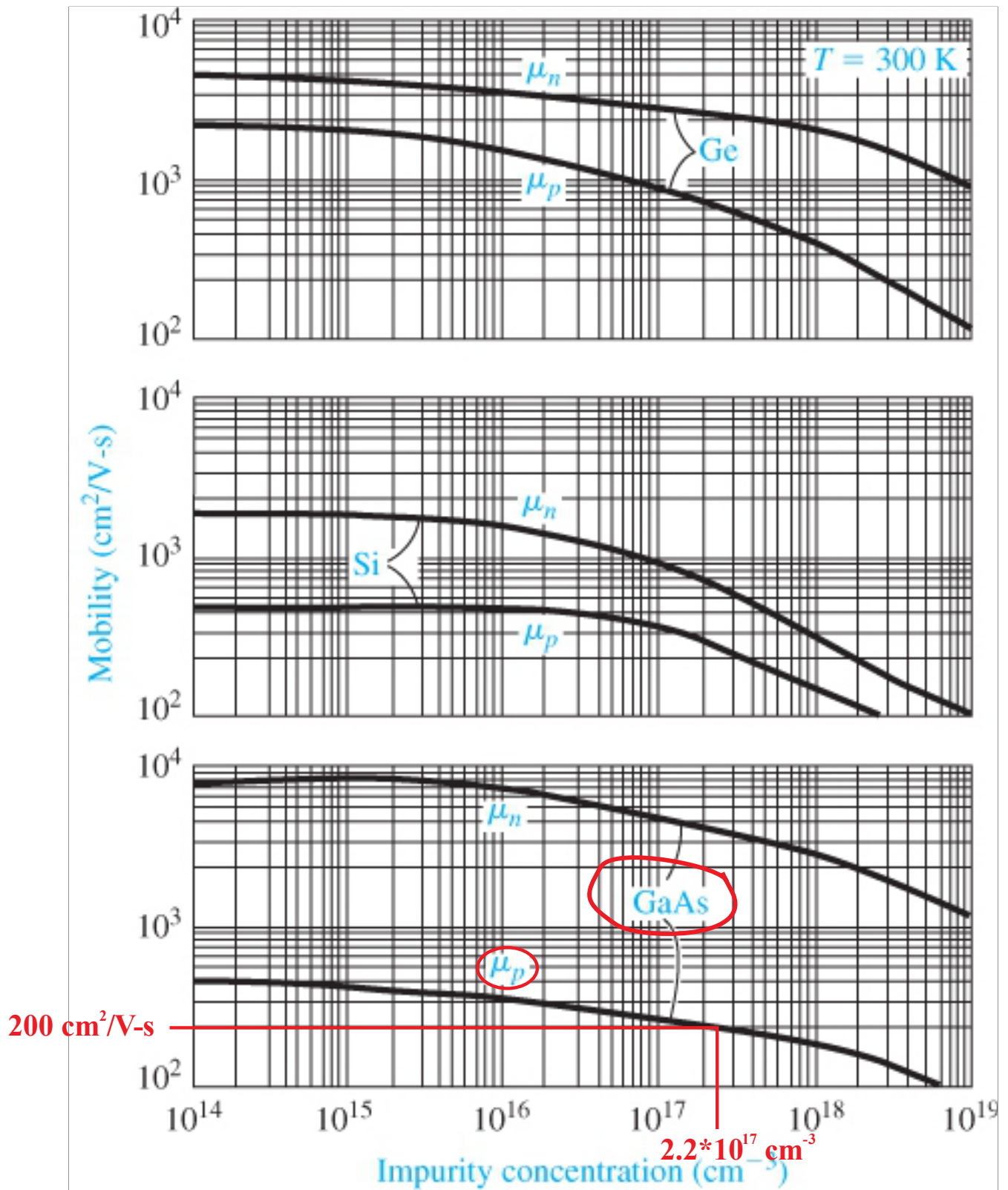


Figure 5.3 | Electron and hole mobilities versus impurity concentrations for germanium, silicon, and gallium arsenide at $T = 300\text{ K}$. (From Sze [14].)

EE 362 Electronic, Magnetic, & Opt. Prop. of Mat'ls Quiz 6 (Spring 2025)Name KEY B

Instructions: Open book/notes. Place answers in indicated spaces and **show all** work for credit. Carry *at least 6* significant figures on constants/parameters in calculations. Give answers with **3-4** significant figures.

A sample of germanium (Ge) has an intrinsic carrier concentration of $2.45 \times 10^{13} \text{ \#/cm}^3$, $E_g = 0.667 \text{ eV}$, and minority excess carrier lifetime of 0.25 \mu s at **300 K**. This sample is doped only with donors to a concentration of $4.1 \times 10^{17} \text{ \#/cm}^3$. Determine the thermal equilibrium electron and hole concentrations (\#/cm^3). Will the minority excess carriers be electron or holes? Then, find the ambipolar mobility ($\text{cm}^2/\text{V}\cdot\text{s}$) and diffusion (cm^2/s) coefficients under low-level injection conditions.

$$\text{Since } N_d \gg n_i \Rightarrow \underline{n_0 \cong N_d = 4.1 \times 10^{17} \text{ \#/cm}^3}.$$

$$(4.43) \ n_i^2 = n_0 p_0 \Rightarrow p_0 = n_i^2 / n_0 = (2.45 \times 10^{13})^2 / 4.1 \times 10^{17} \Rightarrow \underline{p_0 = 1.464 \times 10^9 \text{ \#/cm}^3}.$$

‘doped only with donors’ implies an n-type semiconductor (electrons in majority)
 \Rightarrow holes will be minority excess carriers

(6.47) & (6.48) give the ambipolar diffusion $D' = D_p$ and mobility $\mu' = -\mu_p$ coefficients for an **n-type** semiconductor w/ low-level injection.

Using Figure 5.3 (top graph for germanium), draw a vertical line up from $N_i = N_d = 4.1 \times 10^{17} \text{ \#/cm}^3$ and read hole mobility to be $\mu_p = 500 \text{ cm}^2/\text{V}\cdot\text{s}$

$$\Rightarrow \underline{\mu' = -500 \text{ cm}^2/\text{V}\cdot\text{s}}.$$

Use Einstein Relation (5.47), $\frac{D_p}{\mu_p} = \frac{k_B T}{e}$ to get the hole diffusion coefficient-

$$D_p = \frac{k_B T}{e} \mu_p = \frac{1.380649 \times 10^{-23} (300)}{1.602176634 \times 10^{-19}} 500 \Rightarrow \underline{D_p = D' = 12.926 \text{ cm}^2/\text{s}}.$$

minority excess carriers: electrons or holes (circle correct)

$$n_0 = \underline{4.1 \times 10^{17} \text{ \#/cm}^3} \quad p_0 = \underline{1.464 \times 10^9 \text{ \#/cm}^3}$$

ambipolar mobility = $\mu' = -500 \text{ cm}^2/\text{V}\cdot\text{s}$ ambipolar diff. coeff. = $D' = 12.926 \text{ cm}^2/\text{s}$

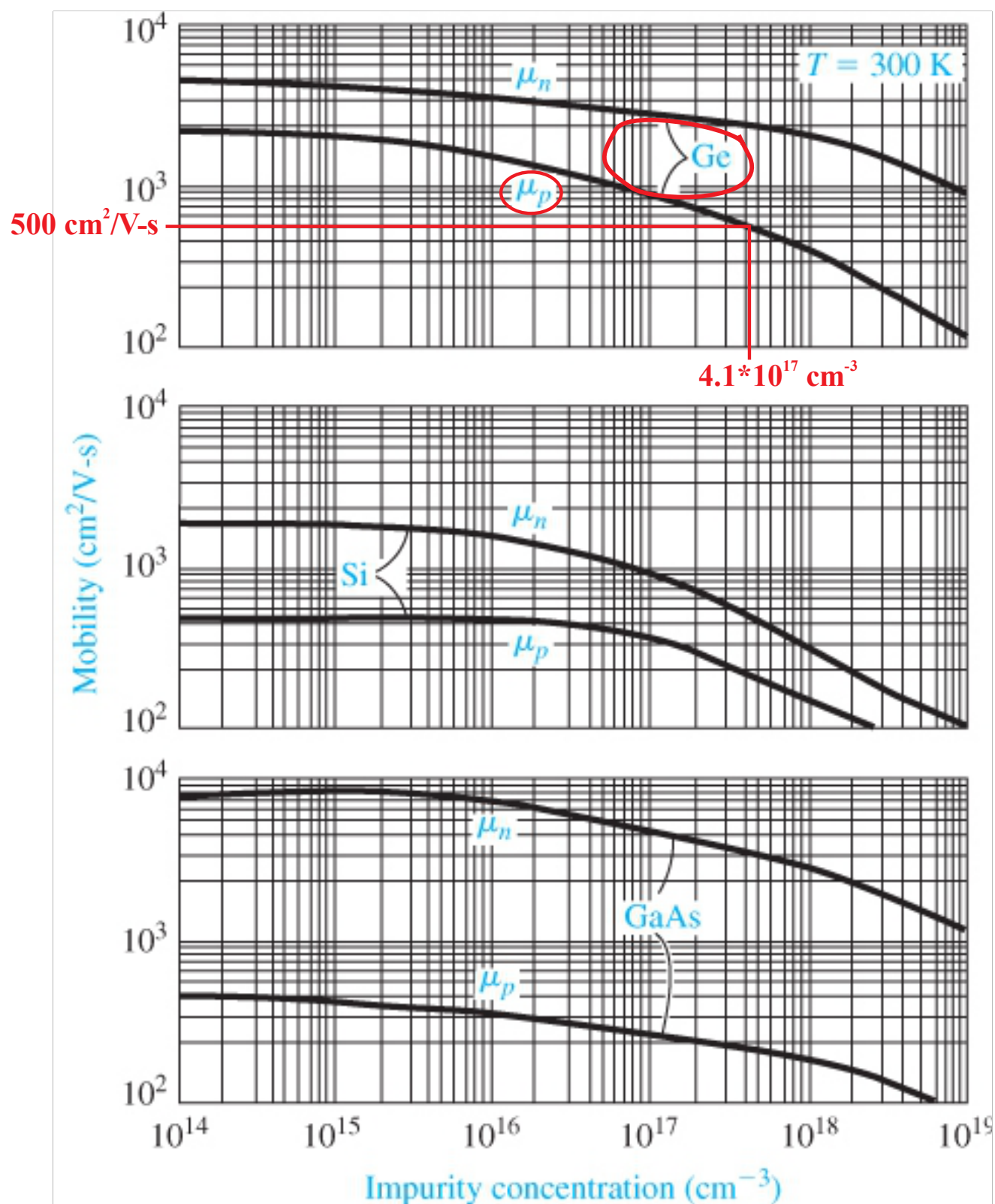


Figure 5.3 | Electron and hole mobilities versus impurity concentrations for germanium, silicon, and gallium arsenide at $T = 300\text{ K}$. (From Sze [14].)